## Author Index of Volume 238


Achour, S., 110
Agabekov, V. E., 141
Ahmed, S., 191
Akimov, A. G., 15

Bak, G. W., 290
Balland, B., 31
Bang, K., 172
Barborica, A., 276
Belu-Marian, A., 312
Benlahrache, M. T., 110
Bhasin, K. B., 123
Bhuiyan, A. H., 191
Bogomlov, D. B., 15
Bouillon, F., 62
Brandel, V., 73
Brodie, D. E., 95
Bryce, M. R., 280
Bureau, J. C., 31

Całusiński, B., 271
Cameron, D. C., 83
Capellades, R., 79
Chandra, S., 167
Chen, M.-C., 146
Chitica, N., 276
Climent, F., 79
Cooke, G., 280

Dat, R., 133
Day, A. E., 207
De Nitti, C., 127
Dinescu, M., 276
Ditina, Z. Z., 27
Dubrovsky, T., 127
Dupuy, J. C., 31

Eisele, I., 27
El-Zahed, H., 104
En, C., 54
Erokhin, V., 88, 127
Evans, B. L., 54

Flynn, D. I., 54
Frolov, S. I., 119

Garcia, E., 79
Garcia, V., 31
Genet, M., 73
George, B., 295
Ghajar, A. J., 172
Ghanbaja, J., 295
Gheber, L. A., 1
Gil, J., 79
Glachant, A., 31
Goldenberg, L. M., 280
Gorodetskii, A. E., 15
Gorodetsky, G., 1
Gudimenko., Yu. I., 141
Gussoni, A., 127

Hagemeyer, A., 184
Harabi, A., 110
Haram, S. K., 21
Hecht, D., 258
Hibst, H., 184
Holloway, P. H., 123
Huang, Y. S., 158

Ignasheva, O. E., 141
Islam, O., 191
Ivanov, I., 312
Ivko, A. A., 141

Jackson, A. D., 4
Jardinier-Offergeld, M., 62
Jergel, M., 295
Johansson, L.-S., 242
Jones, P. A., 4
Jou, J.-H., 70
Jou, K.-W., 70
Joubert, J. C., 218
Juhanoja, J., 242
Jung, M., 12

Kang, W. N., 12
Kasica, H., 266
Kautek, W., 213
Kazanskii, L. P., 15
Khazan, L. S., 51
Khodan, A. N., 15
Khokle, W. S., 155
Kim, T. W., 12
Kizler, P., 184
Klyui, N. I., 119
Kohiki, S., 195
Komanduri, R., 172
Konakova, R. V., 51
Kons, P., 62
Kruk, M., 302
Krylov, I. L., 15
Kumarasinghe, A. R., 101

Lal, K., 155
Langeron, J.-P., 15
Langlet, M., 218
Lee, J. Y., 12
Liang, J. S., 158
Liao, C.-N., 70
Lickiss, P. D., 4
Lifshits, V. G., 27
Lindström, J., 8
Lipiński, A., 266, 290
Litovchenko, V. G., 119
Lorenzi, G. P., 285
Lou, L., 73
Luby, S., 295

Majkova, E., 295
Malhotra, L. K., 167
Mănăilă, R., 312
Maoujoud, M., 62

Mar, S. Y., 158
Marage, P., 218
Maynard, L., 37
Melnikova, N. A., 15
Michel, D., 15
Milenin, V. V., 51
Milhailescu, I. N., 276
Miranda, F. A., 123
Mizukami, F., 163
Mohan Rao, G., 115
Mohan, S., 115
Monjushiro, H., 195
Monkman, A. P., 280
Mueller, C. H., 123
Muralidhar, G. K., 115
Mutikainen, R., 248
Mycielski, W., 266

Naumovets, A. A., 51
Negami, T., 195
Nicolini, C., 88, 127
Nishide, T., 63
Nishitani, M., 195

Olesik, J., 271

Paine, D. C., 44
Park, T. H., 12
Patrykiejew, A., 302
Paul, J., 8
Pearson, C., 280
Perrière, J., 15
Petty, M. C., 280
Pfender, E., 228
Pilkington, R. D., 4
Pimenta, G., 213
Plossu, C., 31
Rastogi, A. C., 167
Rohde, M., 199
Römer, D. U., 285
Ryzhkov, S. V., 27

Santhanam, K. S. V., 21
Senderak, R., 295
Soe, K. Y., 12
Serbănescu, M. D., 312
Shao, Y., 8
Shigesato, Y., 44
Shinoda, M., 163
Simoni, E., 73
Singh, A., 155
Singh, J., 133
Sirimanne, P. M., 101
Sokolowski, S., 302
Stark, D., 258
Staryga, E., 266
Straboni, A., 31
Sun, C. Y., 158

Tanatar, M. A., 119
Tang, W., 83

Tennakone, K., 101
Teodorescu, V., 312
Thompson, D. G., 37
Tkhorik, Yu. A., 51
Tomlinson, R. D., 4
Tronin, A., 127

Ursu, I., 276

Vaezzadeh, M., 295
Vakula, S., 88
Vdovin, V. I., 51
Vellaikal, M., 133
Venkatesan, V., 37
Vignes, J.-L., 15
Volterra, V., 1
von Windheim, J. A., 37

Wada, T., 195
Watanabe, I., 195
Weisenhorn, G. P., 285
Wittmann, F., 27

Xu, S., 54

Yang, F.-M., 146
Yefanov, V. S., 119
Yokoyama, Yu., 195
Yom, S. S., 12
Yoon, Y. S., 12

Zabinski, J. S., 207
Zhang, D. H., 95
Zotov, A. V., 27

# Subject Index of Volume 238


Adhesion
  photoacoustic characterization of thermal transport properties in thin films and microstructures, 199
Adsorption
  crossover from strong to intermediate substrate regimes in multilayer adsorption, 302
Aluminium
  multiple layer coating scheme to protect polymer films from atomic oxygen erosion, 248
Aluminium nitride
  multiple layer coating scheme to protect polymer films from atomic oxygen erosion, 248
Amorphous materials
  electrical and structural studies of $AgSbSe_2$ thin films, 104
Annealing
  low-energy (3–100 eV) electron-bombardment-induced nitridation of thin $SiO_2$ films: physicochemical and electrical analyses, 31
  phase transformation of Mo and W over Co or its alloy in contact with Si, 146
Anodic oxidation
  anodic oxidation of sintered tantalum, 79
Atomic force microscopy
  applicability of the Tougaard ratio $D$ in the analysis of nanometric $TiO_2$ overlayers, 242

Band structure
  oxygen plasma treatment effect on optical properties of $GdBa_2Cu_3O_{7-x}$ high-$T_c$ superconducting films, 119
  UV photoelectron yield spectroscopy of chalcopyrite structure Cu–In–Se thin films, 195
Biomaterials
  Langmuir–Blodgett films of immunoglobulines IgG. Ellipsometric study of the deposition process and of immunological activity, 127

Cadmium sulphide
  defect distribution in electron-irradiated CdS materials, 110
  photocurrent enhancement in a cadmium sulphide anode coated with Prussian blue, 101
Chalcogens
  pyrite film formation by $H_2S$ reactive annealing of iron, 213
Chemical vapour deposition
  effect of substrate surface temperature on the morphology and quality of diamond films produced by the oxyacetylene combustion method, 172
  gas flow effects in synthesis of diamond by hot-filament chemical vapor deposition, 133
  vacuum-deposited thin films of 3-methacryloyloxy-9-diethylamino-5-dicyanomethylene-5*H*-benzo[*a*]phenoxamine, 141
Chemisorption
  effects of annealing ZnO films prepared by ion-beam-assisted reactive deposition, 95
Chromium
  phase segregation in vapour-deposited Co–Cr magnetic thin films, observed by X-ray absorption fine structure spectroscopy, 184
  selective laser oxidation of thin metal film as an effect of different thermal regimes, 276
Coatings
  multiple layer coating scheme to protect polymer films from atomic oxygen erosion, 248
  new route for the deposition of $SiO_2$ sol–gel coatings, 218
  photoacoustic characterization of thermal transport properties in thin films and microstructures, 199
  plasma jet behavior and modeling associated with the plasma spray process, 228
Cobalt
  phase segregation in vapour-deposited Co–Cr magnetic thin films, observed by X-ray absorption fine structure spectroscopy, 184
  phase transformation of Mo and W over Co or its alloy in contact with Si, 146
Conductivity
  electronic transport and localized states distribution in thin coronene layers, 266
  photoacoustic characterization of thermal transport properties in thin films and microstructures, 199
  transport properties of delta-doped Si:Sb superlattices, 27
Crystallization
  effect of substrate surface temperature on the morphology and quality of diamond films produced by the oxyacetylene combustion method, 172
  electrical and structural studies of $AgSbSe_2$ thin films, 104

Deposition process
  effect of substrate surface temperature on the morphology and quality of diamond films produced by the oxyacetylene combustion method, 172
  new route for the deposition of $SiO_2$ sol–gel coatings, 218
Depth profiling
  photoacoustic characterization of thermal transport properties in thin films and microstructures, 199
Diamond
  application of ion-assisted electron beam metallization to diamond electronics, 37
  effect of substrate surface temperature on the morphology and quality of diamond films produced by the oxyacetylene combustion method, 172
  gas flow effects in synthesis of diamond by hot-filament chemical vapor deposition, 133
Dielectric properties
  IR and dielectric studies of plasma-polymerised *m*-xylene thin films, 191
Dielectrics
  anodic oxidation of sintered tantalum, 79
  space charge-limited currents in thin film solid dielectrics with non-uniform deep-trap distributions: numerical solutions, 290
Diffusion
  on a diffusion mechanism of intrinsic stress relaxation in the AuGe–GaAs contacts, 51

Elastic properties
  resistivity and magnetoresistance–elastoresistance of polycrystalline Ni–Si thin films, 312
Electrical properties and measurements
  aluminum-doped zinc oxide transparent conductors deposited by the sol–gel process, 83
  effect of substrate orientation on $WSi_2$ formation, 155

effects of annealing ZnO films prepared by ion-beam-assisted reactive deposition, 95
electrical and structural properties of thin gold films on glass substrates, 258
electrical and structural studies of $AgSbSe_2$ thin films, 104
fabrication and performance study of a $YBa_2Cu_3O_{7-\delta}$ thin film varistor, 115
resistivity and magnetoresistance-elastoresistance of polycrystalline Ni–Si thin films, 312
space charge-limited currents in thin film solid dielectrics with non-uniform deep-trap distributions: numerical solutions, 290
Electrochemistry
electrochemical properties of hexadecanoyltetrathiafulvalene Langmuir–Blodgett films, 280
electroless deposition of orthorhombic copper (I) selenide and its room temperature phase transformation to cubic structure, 21
Electron emission
UV photoelectron yield spectroscopy of chalcopyrite structure Cu–In–Se thin films, 195
Electron microscopy
electrical and structural studies of $AgSbSe_2$ thin films, 104
formation of zirconia–ceria layers on silicon wafers using laser ablation, 15
Electron scattering
grain boundary scattering in ruthenium dioxide thin films, 158
Ellipsometry
Langmuir–Blodgett films of immunoglobulines IgG. Ellipsometric study of the deposition process and of immunological activity, 127
oxygen plasma treatment effect on optical properties of $GdBa_2Cu_3O_{7-x}$ high-$T_c$ superconducting films, 119
structural, optical and magnetic properties of $Cd_{0.77}Mn_{0.23}Te$ thin films, 167
Epitaxy
C-growth of d.c.-sputtered Mo and W thin films, 62
effect of oxygen pressure on the orientation of $YBa_2Cu_3O_{7-x}/SrTiO_3$ films deposited on (1102) $Al_2O_3$ substrates, 123
formation of zirconia–ceria layers on silicon wafers using laser ablation, 15
Evaporation
spectroscopic investigations of the drying process of phosphate solutions leading to transparent thin films, 73
structural, optical and magnetic properties of $Cd_{0.77}Mn_{0.23}Te$ thin films, 167

Field effect
influence of an internal electric field in a sample on the secondary electron emission phenomenon, 271

Gallium arsenide
method for the determination of gold thin film's mechanical properties, 70
on a diffusion mechanism of intrinsic stress relaxation in the AuGe–GaAs contacts, 51
Glass
electrical and structural properties of thin gold films on glass substrates, 258
influence of an internal electric field in a sample on the secondary electron emission phenomenon, 271
Gold
electrical and structural properties of thin gold films on glass substrates, 258
method for the determination of gold thin film's mechanical properties, 70
Grain boundary
grain boundary scattering in ruthenium dioxide thin films, 158
Growth mechanism
microstructural study of low resistivity tin-doped indium oxide prepared by d.c. magnetron sputtering, 44
pyrite film formation by $H_2S$ reactive annealing of iron, 213
study of island growth of ion beam sputtered metal films by digital image processing, 54

Hall effect
transport properties of delta-doped Si:Sb superlattices, 27
Hydrogen
low-energy (3–100 eV) electron-bombardment-induced nitridation of thin $SiO_2$ films: physicochemical and electrical analyses, 31
Hydrogen sulphide
pyrite film formation by $H_2S$ reactive annealing of iron, 213

Indium oxide
microstructural study of low resistivity tin-doped indium oxide prepared by d.c. magnetron sputtering, 44
Infrared spectroscopy
IR and dielectric studies of plasma-polymerised *m*-xylene thin films, 191
Interfaces
on a diffusion mechanism of intrinsic stress relaxation in the AuGe–GaAs contacts, 51
Ion bombardment
application of ion-assisted electron beam metallization to diamond electronics, 37
vacuum-deposited thin films of 3-methacryloyloxy-9-diethylamino-5-dicyanomethylene-5*H*-benzo[*a*]phenoxamine, 141

Langmuir–Blodgett films
electrochemical properties of hexadecanoyltetrathiafulvalene Langmuir–Blodgett films, 280
Langmuir–Blodgett films of immunoglobulines IgG. Ellipsometric study of the deposition process and of immunological activity, 127
nanothin films of tubular oligopeptides; monolayers and Langmuir–Blodgett films of $\beta^{4.4}$-helices with surface-pressure-dependent orientation, 285
reversed micellar approach as a new tool for the formation and structural studies of protein Langmuir–Blodgett films, 88
Laser ablation
effect of oxygen pressure on the orientation of $YBa_2Cu_3O_{7-x}/SrTiO_3$ films deposited on (1102) $Al_2O_3$ substrates, 123
formation of zirconia–ceria layers on silicon wafers using laser ablation, 15
parametric study of pulsed laser deposited niobium diselenide thin-film growth, 207
Laser irradiation
selective laser oxidation of thin metal film as an effect of different thermal regimes, 276
vacuum-deposited thin films of 3-methacryloyloxy-9-diethylamino-5-dicyanomethylene-5*H*-benzo[*a*]phenoxamine, 141
Lattice parameters
effect of oxygen pressure on the orientation of $YBa_2Cu_3O_{7-x}/SrTiO_3$ films deposited on (1102) $Al_2O_3$ substrates, 123

Luminescence
defect distribution in electron-irradiated CdS materials, 110
Magnetic properties and measurements
resistivity and magnetoresistance-elastoresistance of polycrystalline Ni–Si thin films, 312
Metallization
application of ion-assisted electron beam metallization to diamond electronics, 37
Molybdenum
C-growth of d.c.-sputtered Mo and W thin films, 62
phase transformation of Mo and W over Co or its alloy in contact with Si, 146
Monolayers
nanothin films of tubular oligopeptides; monolayers and Langmuir–Blodgett films of $\beta^{4,4}$-helices with surface-pressure-dependent orientation, 285
reversed micellar approach as a new tool for the formation and structural studies of protein Langmuir–Blodgett films, 88
Multilayers
characterization of obiquely deposited tungsten/silicon multilayers, 295
crossover from strong to intermediate substrate regimes in multilayer adsorption, 302

Nanostructures
applicability of the Tougaard ratio $D$ in the analysis of nanometric $TiO_2$ overlayers, 242
Nickel
resistivity and magnetoresistance-elastoresistance of polycrystalline Ni–Si thin films, 312
Niobium
parametric study of pulsed laser deposited niobium diselenide thin-film growth, 207
Nucleation
study of island growth of ion beam sputtered metal films by digital image processing, 54

Optical coatings
aluminum-doped zinc oxide transparent conductors deposited by the sol–gel process, 83
Optical properties
spectroscopic investigations of the drying process of phosphate solutions leading to transparent thin films, 73
Optical spectroscopy
plasma jet behavior and modeling associated with the plasma spray process, 228
Organic substances
electronic transport and localized states distribution in thin coronene layers, 266
IR and dielectric studies of plasma-polymerised $m$-xylene thin films, 191
Oxidation
anodic oxidation of sintered tantalum, 79
selective laser oxidation of thin film as an effect of different thermal regimes, 276
Oxides
grain boundary scattering in ruthenium dioxide thin films, 158

Phase transitions
crossover from strong to intermediate substrate regimes in multilayer adsorption, 302
electroless deposition of orthorhombic copper (I) selenide and its room temperature phase transformation to cubic structure, 21
Photoconductivity
electronic transport and localized states distribution in thin coronene layers, 266
photocurrent enhancement in a cadmium sulphide anode coated with Prussian blue, 101
Photodesorption
effects of annealing ZnO films prepared by ion-beam-assisted reactive deposition, 95
Photoelectron spectroscopy
UV photoelectron yield spectroscopy of chalcopyrite structure Cu-In-Se thin films, 195
Physical vapour deposition
vacuum-deposited thin films of 3-methacryloyloxy-9-diethylamino-5-dicyanomethylene-5$H$-benzo[$a$]phenoxamine, 141
Plasma processing and deposition
IR and dielectric studies of plasma-polymerised $m$-xylene thin films, 191
plasma jet behavior and modeling associated with the plasma spray process, 228

Radiation damage
low-energy (3–100 eV) electron-bombardment-induced nitridation of thin $SiO_2$ films: physicochemical and electrical analyses, 31

Schottky barrier
application of ion-assisted electron beam metallization to diamond electronics, 37
Secondary electron emission
influence of an internal electric field in a sample on the secondary electron emission phenomenon, 271
Segregation
phase segregation in vapour-deposited Co–Cr magnetic thin films, observed by X-ray absorption fine structure spectroscopy, 184
Selenides
electroless deposition of orthorhombic copper (I) selenide and its room temperature phase transformation to cubic structure, 21
parametric study of pulsed laser deposited niobium diselenide thin-film growth, 207
Semiconductors
defect distribution in electron-irradiated CdS materials, 110
pyrite film formation by $H_2S$ reactive annealing of iron, 213
Sensors
Langmuir–Blodgett films of immunoglobulines IgG. Ellipsometric study of the deposition process and of immunological activity, 127
Silane
Langmuir–Blodgett films of immunoglobulines IgG. Ellipsometric study of the deposition process and of immunological activity, 127
Silicides
effect of substrate orientation on $WSi_2$ formation, 155
phase transformation of Mo and W over Co or its alloy in contact with Si, 146
Silicon
characterization of obiquely deposited tungsten/silicon multilayers, 295
formation of zirconia–ceria layers on silicon wafers using laser ablation, 15
method for the determination of gold thin film's mechanical properties, 70
transport properties of delta-doped Si:Sb superlattices, 27
Silicon oxide
new route for the deposition of $SiO_2$ sol–gel coatings, 218

low-energy (3–100 eV) electron-bombardment-induced nitridation of thin $SiO_2$ films: physicochemical and electrical analyses, 31
Sputtering
microstructural study of low resistivity tin-doped indium oxide prepared by d.c. magnetron sputtering, 44
C-growth of d.c.-sputtered Mo and W thin films, 62
fabrication and performance study of a $YBa_2Cu_3O_{7-\delta}$ thin film varistor, 115
study of island growth of ion beam sputtered metal films by digital image processing, 54
Stress
on a diffusion mechanism of intrinsic stress relaxation in the AuGe–GaAs contacts, 51
Structural properties
electrical and structural properties of thin gold films on glass substrates, 258
influence of an internal electric field in a sample on the secondary electron emission phenomenon, 271
structural, optical and magnetic properties of $Cd_{0.77}Mn_{0.23}Te$ thin films, 167
Superconductivity
effect of oxygen pressure on the orientation of $YBa_2Cu_3O_{7-x}/SrTiO_3$ films deposited on (1102) $Al_2O_3$ substrates, 123
fabrication and performance study of a $YBa_2Cu_3O_{7-\delta}$ thin film varistor, 115
oxygen plasma treatment effect on optical properties of $GdBa_2Cu_3O_{7-x}$ high-$T_c$ superconducting films, 119
Superlattices
transport properties of delta-doped Si:Sb superlattices, 27
Surface and interfaces
UV photoelectron yield spectroscopy of chalcopyrite structure Cu–In–Se thin films, 195
Surface morphology
study of island growth of ion beam sputtered metal films by digital image processing, 54
Surface pressure
nanothin films of tubular oligopeptides; monolayers and Langmuir–Blodgett films of $\beta^{4.4}$-helices with surface-pressure-dependent orientation, 285
Surface stress
structural, optical and magnetic properties of $Cd_{0.77}Mn_{0.23}Te$ thin films, 167
Synthesis
gas flow effects in synthesis of diamond by hot-filament chemical vapor deposition, 133

Tantalum
anodic oxidation of sintered tantalum, 79
Titanium oxide
applicability of the Tougaard ratio $D$ in the analysis of nanometric $TiO_2$ overlayers, 242
Transmission electron microscopy
microstructural study of low resistivity tin-doped indium oxide prepared by d.c. magnetron sputtering, 44
Tribology
parametric study of pulsed laser deposited niobium diselenide thin-film growth, 207
Tungsten
C-growth of d.c.-sputtered Mo and W thin films, 62
characterization of obiquely deposited tungsten/silicon multilayers, 295
effect of substrate orientation on $WSi_2$ formation, 155
method for the determination of gold thin film's mechanical properties, 70

X-ray absorption
phase segregation in vapour-deposited Co–Cr magnetic thin films, observed by X-ray absorption fine structure spectroscopy, 184
X-ray diffraction
characterization of obiquely deposited tungsten/silicon multilayers, 295
effect of substrate orientation on $WSi_2$ formation, 155
electrical and structural studies of $AgSbSe_2$ thin films, 104
electroless deposition of orthorhombic copper (I) selenide and its room temperature phase transformation to cubic structure, 21
X-ray photoelectron spectroscopy
applicability of the Tougaard ratio $D$ in the analysis of nanometric $TiO_2$ overlayers, 242

Zinc oxide
aluminum-doped zinc oxide transparent conductors deposited by the sol–gel process, 83
effects of annealing ZnO films prepared by ion-beam-assisted reactive deposition, 95